



- (a)  $n$  must be zero                      (b)  $p$  must be zero  
 (c)  $n$  and  $p$  must be equal            (d)  $n$  and  $p$  must not be equal

8. In an n-type semiconductor, if  $n$  and  $p$  are the electron and hole concentrations, .....

- (a)  $n$  must be zero                      (b)  $p$  must be zero  
 (c)  $n$  is smaller than  $p$                 (d)  $n$  is larger than  $p$

9. In a p-type semiconductor, if  $n$  and  $p$  are the electron and hole concentrations, .....

- (a)  $n$  must be zero                      (b)  $p$  must be zero  
 (c)  $n$  is smaller than  $p$                 (d)  $n$  is larger than  $p$

**Solve the following problems**

[1] For intrinsic silicon at room temperature, given that the intrinsic concentration is  $1 \times 10^{10} \text{ cm}^{-3}$ , the mean time between scatterings is  $2 \times 10^{-13} \text{ sec}$  for electrons, and  $1 \times 10^{-13} \text{ sec}$  for holes, the conductivity effective mass for electrons is  $0.26m_0$ , and  $0.386m_0$  for holes, where  $m_0$  is the rest mass for the electrons. Find:

- a. Electron and hole mobilities
- b. Total conductivity.
- c. The current density if the silicon has a length of  $1 \mu\text{m}$ , and an applied voltage of  $10\text{V}$ .
- d. The total current if the cross section area is  $100 \mu\text{m}^2$ .

Hint: use MKS system

[2] Plot the Fermi-Dirac distribution if Fermi-Level is located at  $0.56 \text{ eV}$  for  $T=0\text{K}, 1000\text{K}$ .

[3] Plot the Fermi-Dirac distribution for intrinsic silicon at  $T=1000\text{K}$  if  $E-E_f = \pm 0.3$ ,  $E-E_f = \pm 0.6$ .

[4] Example 5.3 p.392.

[5] For a p-type silicon slice with:

- Cross section area =  $10 \mu\text{m}^2$ , length =  $100 \mu\text{m}$ , mobility =  $600 \text{ cm}^2\text{V}^{-1}\text{sec}^{-1}$ , temperature =  $27^\circ\text{C}$ .
- Boron (Acceptor,  $N_A$ ) doping gradient with a linear dependence on distance, with  $N_A(\text{at } x=0\mu\text{m}) = 5 \times 10^{16} \text{ cm}^{-3}$ , and  $N_A(\text{at } x= 100\mu\text{m}) = 10^{17} \text{ cm}^{-3}$ .

Find the total diffusion current.

Note: Use  $k= 1.3806488 \times 10^{-23} \text{ J.K}^{-1}$ .

[6] For silicon at  $T=300\text{K}$ , given that the value of  $N_c=2.8 \times 10^{19} \text{ cm}^{-3}$  and  $N_v=1.04 \times 10^{19} \text{ cm}^{-3}$ , find:

- a) The electron concentration for an n-type doped semiconductor if  $E_F$  is located at  $146 \text{ meV}$  below  $E_C$ .
- b) The hole concentration for a p-type doped semiconductor if  $E_F$  is located at  $0.31 \text{ eV}$  above  $E_v$ .